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Full Paper

Thermodynamics of chemical and electrochemical stability of alloys of the Ti-Si system

© Pavel A. Nikolaychuk,⁺ and Alexander G. Tyurin*

Department of Analytical and Physical Chemistry. Chelvabinsk State University. Brat'ev Kashirinykh St., 129. Chelyabinsk, 454026. Russia. Phone: +7 (351) 799-70-69. E-mail: npa@csu.ru, tag@csu.ru.

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Abstract

A phase diagram of Ti-Si-O system state and a potential – pH diagram of Ti-Si-H2O system at 25 $^{\circ}$ C, air pressure of 1 bar and activities of ions in solution equal to 1 $^{mole}/_{1}$ are plotted with and without the account of titanium hydride and nitride formation are plotted. The corrosion-electrochemical behaviour of alloys in the Ti-Si system in aqueous media is considered.